Optimizing the Dose for Energy Dispersive Electron Probe X-ray Microanalysis Measurements

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Achieving the desired measurement precision without wasting time can be a challenge. One common strategy is to collect for a duration that seems "more than long enough" to the analyst. This approach is often wasteful of time but more often it underestimates the dose requirements to achieve the desired precision. Within a single sample, the dose requirements to measure a major element (C>0.10) and a minor element (0.10 > C > 0.01) to the same precision can easily vary by two orders-of-magnitude and often significantly more. Another approach is to make the measurement, consider the reported measurement precision and then adjust the dose to meet the desired precision goals. This depends upon actually being able to determine the measurement uncertainty, an important piece of information which all too few energy dispersive spectrometer vendor applications actually report.

A better way is to simulate dose correct spectra and to use these spectra to estimate the required dose to perform the measurement. It can be argued from basic statistics and demonstrated with measurements that, to a very good approximation, the precision of an x-ray spectroscopy measurement scales as the dose where the dose is the product of the live time and the probe current. Increasing the dose by a factor of a hundred will only improve the precision ten-fold.

NIST DTSA-II makes it easy to simulate dose-correct spectra and to quantify these spectra as though they were measured spectra. However, this process is tedious. To simplify the measurement design process, NIST DTSA-II has a number of optimization tools. One aspect of these tools, the ability to optimize the selection of standard material to minimize the uncertainty due to the matrix correction, was discussed last year [1]. This year we will discuss how to use expert-mode tools to optimize the dose and thus allow you to design a measurement which will achieve your measurement goals in the minimum amount of measurement time and the minimum amount of sample exposure and possible damage.

The expert tool asks you to provide precision goals for each element and the conditions under which you intend on making the measurement. It then uses analytical model simulations of the measured standard, unknown, and reference x-ray spectra, followed by linear least squares fitting of top-hat filtered spectra to determine the measurement precision for a default dose. The measurement precision is then compared to the desired precision on an element-by-element basis and the doses for the standard, unknown and references are scaled to achieve the desired precision. The results are reported as a list of required spectra with the optimal dose. Furthermore, an estimate of the more complete uncertainty budget including terms for precision and matrix correction uncertainties is reported. This allows you to determine before the measurement is made whether the measurement will be useful for the desired purpose.

One surprising outcome is that while the standard and unknown doses are critical in determining the measurement precision, the reference doses are much less significant. This is to say that it is far better to

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spend your limited laboratory time collecting the standards and unknown spectra. References matter but not nearly as much as intuition suggests.

[1] NWM Ritchie, "Designing the optimal quantitative electron probe x-ray microanalysis measurement", Microscopy and Microanalysis, 19 Supplement S2, 2013, pp 1248 – 1249

Material	Dose	Transition	Reason	
Unknown	6 nA·s	ОК	Unknown	
Al2O3	1.2 nA⋅s	ОК	Ref against unknown for O	
Unknown	2.5 nA⋅s	Si K	Unknown	
Unknown	34 nA⋅s	Τί Κα	Unknown	
Ti	0.8 nA·s	Τί Κα	Ref against unknown for Ti Kα	
Unknown	24 nA⋅s	Ba Lα	Unknown	
BaCl	3.4 nA⋅s	Ba Lα	Ref against unknown for Ba Lα	
Benitoite	6 nA·s	ОК	Standard	
Ti	0.5 nA·s	Ti L	Ref against standard for O K	
Al2O3	3.5 nA⋅s	ОК	Ref against standard for O K	
BaCl	1.2 nA⋅s	Ba M	Ref against standard for O K	
Benitoite	3.1 nA·s	Si K	Standard	
Benitoite	7.2 nA·s	Τί Κα	Standard	
BaCl	1.3 nA⋅s	Ba Lα	Ref against standard for Ti Kα	
Ti	0.8 nA⋅s	Τί Κα	Ref against standard for Ti Kα	
Benitoite	38 nA⋅s	Ba Lα	Standard	
BaCl	13 nA⋅s	Ba Lα	Ref against standard for Ba Lα	
Ti	4.1 nA⋅s	Τί Κα	Ref against standard for Ba Lα	
Ti	3.9 nA⋅s	Ti Kb	Ref against standard for Ba Lα	

Figure 1. Optimized doses for measuring a glass with 40% Ba, 30% O, 25% Si and 5% Ti using Benitoite as a standard and Al_2O_3 , BaCl and Ti as references. Depending upon its use, each material has different dose requirements. The optimal dose for each material is the minimum dose meeting all requirements.

Composition			Beam Energy (keV)	Form	Preparation	Dose (nA·s)	Туре	
Unknow	n mate	rial						
Element	Mass Fraction	Mass Fraction (normalized)			Bulk			Unknown
0		0.3000	0.5932	15.0		Polished to a 50.0 nm finis	finish 31.0	
Si	0.2500	0.2500	0.2816					
Ti	0.0500	0.0500	0.0330					
Ва	0.4000	0.4000	0.0921					
Al203								
Element	Mass Fraction	Mass Fraction (normalized)	Fraction	15.0	Bulk	Polished to a 50.0 nm finish	h 10.0	Reference
0	0.4707	0.4707	0.6000					
Al	0.5293	0.5293	0.4000					
П								
Element	Mass Fraction	Mass Fraction (normalized)		15.0	Bulk	Polished to a 50.0 nm finish	10.0	Reference
Ti	1.0000	1.0000	1.0000					
BaCl								
Element	Mass Fraction	Mass Fraction (normalized)		15.0	Bulk	Polished to a 50.0 nm finis	h 13.0	Reference
Cl	0.2052	0.2052	0.5000					
Ва	0.7948	0.7948	0.5000					
Benitoit	e.							
Element	Mass Fraction	Mass Fraction (normalized)		15.0	Bulk	Polished to a 50.0 nm finish		Standard
0	0.3483	0.3483	0.6429				n 36.0	
Si	0.2038	0.2038	0.2143					
Ti	0.1158	0.1158	0.0714					
Ва	0.3322	0.3322	0.0714					

Figure 2. This report itemizes the spectra to collect and the form, preparation and dose.